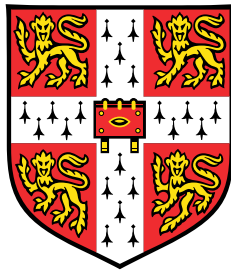


Multi-microscopy Characterisation of III-nitride Devices and Materials



Christopher Xiang Ren

Department of Materials Science and Metallurgy
University of Cambridge

This dissertation is submitted for the degree of
Doctor of Philosophy

Wolfson College

April 2016

I would like to dedicate this thesis to my loving parents ...

Declaration

I hereby declare that except where specific reference is made to the work of others, the contents of this dissertation are original and have not been submitted in whole or in part for consideration for any other degree or qualification in this, or any other university. This dissertation is my own work and contains nothing which is the outcome of work done in collaboration with others, except as specified in the text and Acknowledgements. This dissertation contains fewer than 65,000 words including appendices, bibliography, footnotes, tables and equations and has fewer than 150 figures.

Christopher Xiang Ren
April 2016

Acknowledgements

And I would like to acknowledge ...

Abstract

This is where you write your abstract ...

Table of contents

| | |
|---|-------------|
| List of figures | xiii |
| List of tables | xv |
| Nomenclature | xvii |
| Nomenclature | xix |
| 1 Introduction | 1 |
| 1.1 III-Nitride Material Properties | 2 |
| 1.1.1 Crystal Structure | 2 |
| 1.1.2 Band Structure | 4 |
| 1.1.3 Built-in Fields | 4 |
| 1.1.4 Defects in III-nitrides | 4 |
| 1.2 III-nitride Cavities | 4 |
| 1.2.1 Cavity characteristics | 4 |
| 1.2.2 Cavity Designs | 4 |
| 2 Experimental Methods | 5 |
| 2.1 Atomic Force Microscopy | 6 |
| 2.2 Hyperspectral Electroluminescence Mapping | 6 |
| 2.3 Scanning Electron Microscopy and Cathodoluminescence | 6 |
| 2.4 Photoluminescence | 6 |
| 2.5 Dual Beam Scanning Electron microscopy with a Focussed Ion Beam | 6 |
| 2.5.1 Fabrication | 6 |
| 2.5.2 Tomography | 6 |
| 2.6 Transmission Electron Microscopy | 6 |
| 2.6.1 Tomography | 6 |

| | | |
|----------|--|-----------|
| 3 | Inhomogeneous Electroluminescence in InGaN QW LEDs | 11 |
| 3.1 | Short title | 11 |
| | References | 17 |
| | Appendix A How to install L^AT_EX | 19 |
| | Appendix B Installing the CUED class file | 23 |

List of figures

| | | |
|-----|--|----|
| 1.1 | Unit cell (dashed line) for GaN crystal structure and lattice parameters $\mathbf{a_0}, \mathbf{c_0}$. Adapted from [?] | 3 |
| 1.2 | Illustration of Ga-face (+ c) and N-face (- c) GaN wrutzite crystal exhibiting polarity along the c -axis [8]. | 4 |
| 2.1 | Best Animations | 9 |
| 3.1 | Best Animations | 15 |

List of tables

1.1 Room temperature lattice parameters for GaN, InN and AlN [4]. 3

Nomenclature

Acronyms / Abbreviations

| | |
|------|------------------------------|
| 1-D | One-Dimensional |
| AlN | Aluminium Nitride |
| EL | Electroluminescence |
| ET | Electron Tomography |
| FIBT | Focussed Ion Beam Tomography |
| GaAs | Gallium Arsenide |
| GaN | Gallium Nitride |
| InN | Indium Nitride |
| LED | Light-Emitting Diode |
| SPS | Single Photon Source |

Nomenclature

Acronyms / Abbreviations

1-D One-Dimensional

AlN Aluminium Nitride

EL Electroluminescence

ET Electron Tomography

FIBT Focussed Ion Beam Tomography

GaAs Gallium Arsenide

GaN Gallium Nitride

InN Indium Nitride

LED Light-Emitting Diode

SPS Single Photon Source

Chapter 1

Introduction

Gallium nitride (GaN) has been termed the 'most important semiconductor material since silicon' [1], and indeed the influence of this incredible material and its associated alloys (termed III-nitrides) is pervasive in modern society. The impact of III-nitride materials is perhaps best evidenced by the global transition from traditional lighting sources to semiconductor lighting solutions based on III-nitride materials. Since the first demonstration of a high-brightness blue light emitting diode (LED) in 1991 by Shuji Nakamura [2], the widespread use of LEDs for general lighting purposes has blossomed into a multi-billion pound industry. The extraordinary optical properties of III-nitride materials have enabled their application outside of the lighting industry: the development of III-nitride based lasers has found applications in telecommunications [?], medicine [?] and data storage . Furthermore, III-nitride optical emitters have been used as single photon sources (SPSs) which have applications in cryptography for secure communications [?].

The optoelectronic properties of III-nitride materials are somewhat astonishing: GaN suffers from a defect density several orders of magnitude higher than other optically active semiconductor materials such as gallium arsenide (GaAs) [3] yet is still optically active. Despite this, the effects of defects originating from the heteropitaxial growth of GaN are clearly deleterious when considering III-nitride device operation. This work aims to explore the manner in which the microstructural properties of photonic III-nitride devices affect their performance by combining multiple microscopy techniques, an approach we term 'multi-microscopy', thus allowing us to link specific structural features with emissive properties at the device level. The experimental research in this thesis is separated into four main sections.

The first section details the investigation of inhomogeneous electroluminescence (EL) of indium gallium nitride (InGaN) quantum well (QW) LEDs. By employing the use of scanning probe techniques, electron microscopy and spectroscopy the underpinning cause of LED behaviour was elucidated and reported.

The second section involves microscopy-based investigation into the mechanisms behind incomplete etching in the fabrication of III-nitride based microdisk cavities and the effect of this issue on the overall optical performance of these cavities

The third section describes the microscopy of one dimensional (1-D) photonic crystal cavity (PCC) 'nanobeam' cavities. The intrinsic resistance of III-nitride based materials can often result in improperly etched features, which can results in high optical losses in cavities. This section concerns the use of tomographic techniques such as electron tomography (ET) and focussed ion beam tomography (FIB-T) to investigate the effect of these issues on the emission of III-nitride nanobeam cavities.

1.1 III-Nitride Material Properties

1.1.1 Crystal Structure

GaN can crystallise into two distinct crystal structures: hexagonal (wurtzite) and cubic (zinc blende and rock salt). Under ambient conditions, wurtzite GaN is the most commonly studied form as it is the most structurally stable. Thus, the work discussed in this thesis concerns wurtzite III-nitrides. A schematic of a wurtzite III-nitride crystal structure is shown in Fig.?? and consists of stacked hexagonal close-packed planes following an ABABAB stacking sequence. Atoms of the respective elements are tetrahedrally bonded to one another. However, in the case of III-nitrides this structure deviates from ideal tetrahedral bonding and results in a non-zero dipole moment for each unit cell which will be discussed in the following sections.

A 4-index Miller-Bravais notation ($hkil$) is used to denote the crystal planes where the index i is defined by the relation:

$$i = -(h + k) \quad (1.1)$$

The crystallographic planes (0001), (1-100) and (11-20) shown in Fig.?? are often termed the c , m and a -planes in the literature. The fundamental unit cell of the wurtzite GaN crystal structure and its associated lattice parameters \mathbf{a} and \mathbf{c} is shown in Fig.1.1

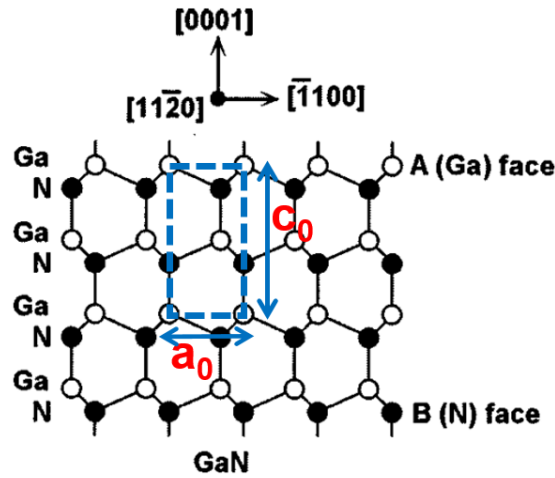


Fig. 1.1 Unit cell (dashed line) for GaN crystal structure and lattice parameters a_0 , c_0 . Adapted from [?]

Other members of the III-nitride materials such as indium nitride (InN) or aluminium nitride (AlN) have different lattice parameters due to the differing atomic radii of aluminium and indium relative to gallium.

| Alloy | a (Å) at $T = 300\text{K}$ | c (Å) at $T = 300\text{K}$ |
|-------|------------------------------|------------------------------|
| GaN | 3.189 | 5.185 |
| InN | 3.545 | 5.703 |
| AlN | 3.112 | 4.982 |

Table 1.1 Room temperature lattice parameters for GaN, InN and AlN [4].

III-nitride photonic devices are often heterostructures consisting of ternary alloys the materials shown in Table ???. Lattice parameters of a relaxed ternary alloy $A_xB_{1-x}N$ can be estimated using Vegard's law [5]:

$$a = xa_{AN} + (1 - x)a_{BN} \quad (1.2)$$

$$c = xc_{AN} + (1 - x)c_{BN} \quad (1.3)$$

Typical indium compositions for blue LEDs range between 15-20 %, which leads to a considerable lattice mismatch of approximately 2 %, resulting in considerable amounts of strain in these GaN/InGaN heterostructures.

1.1.2 Band Structure

One of the principal driving factors behind the interest in III-nitrides for photonic devices is their direct bandgap which collectively spans the visible spectrum and beyond.

1.1.3 Built-in Fields

III-nitride materials in wurtzite structure are termed 'polar' materials, due to the fact they exhibit a spontaneous polarisation field [6]. This occurs due to III-nitride bonding structure deviating from an ideal tetrahedral structure along the (0001) axis along the crystal, combined with the ionicity of the bond [7]. This deviation causes each unit cell to possess a non-zero dipole moment along the principal axis of the tetrahedral bonding structure, resulting in an overall spontaneous polarization in the crystal. As the III-nitride wurtzite structure is non-centrosymmetric, the direction of the polarization depends on whether the crystal exhibits (+*c*) or (-*c*) polarity, as shown in Fig.1.2

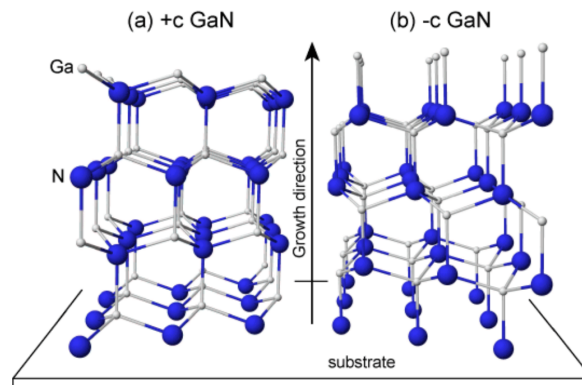


Fig. 1.2 Illustration of Ga-face (+ *c*) and N-face (-*c*) GaN wurtzite crystal exhibiting polarity along the *c*-axis [8].

1.1.4 Defects in III-nitrides

1.2 III-nitride Cavities

1.2.1 Cavity characteristics

1.2.2 Cavity Designs

Chapter 2

Experimental Methods

2.1 Atomic Force Microscopy

2.2 Hyperspectral Electroluminescence Mapping

2.3 Scanning Electron Microscopy and Cathodoluminescence

2.4 Photoluminescence

2.5 Dual Beam Scanning Electron microscopy with a Focussed Ion Beam

2.5.1 Fabrication

2.5.2 Tomography

2.6 Transmission Electron Microscopy

2.6.1 Tomography

2.7 Hidden section

Lorem ipsum dolor sit amet, *consectetur adipiscing elit*. In magna nisi, aliquam id blandit id, congue ac est. Fusce porta consequat leo. Proin feugiat at felis vel consectetur. Ut

tempus ipsum sit amet congue posuere. Nulla varius rutrum quam. Donec sed purus luctus, faucibus velit id, ultrices sapien. Cras diam purus, tincidunt eget tristique ut, egestas quis nulla. Curabitur vel iaculis lectus. Nunc nulla urna, ultrices et eleifend in, accumsan ut erat. In ut ante leo. Aenean a lacinia nisl, sit amet ullamcorper dolor. Maecenas blandit, tortor ut scelerisque congue, velit diam volutpat metus, sed vestibulum eros justo ut nulla. Etiam nec ipsum non enim luctus porta in in massa. Cras arcu urna, malesuada ut tellus ut, pellentesque mollis risus. Morbi vel tortor imperdiet arcu auctor mattis sit amet eu nisi. Nulla gravida urna vel nisl egestas varius. Aliquam posuere ante quis malesuada dignissim. Mauris ultrices tristique eros, a dignissim nisl iaculis nec. Praesent dapibus tincidunt mauris nec tempor. Curabitur et consequat nisi. Quisque viverra egestas risus, ut sodales enim blandit at. Mauris quis odio nulla. Cras euismod turpis magna, in facilisis diam congue non. Mauris faucibus nisl a orci dictum, et tempus mi cursus.

Etiam elementum tristique lacus, sit amet eleifend nibh eleifend sed ¹. Maecenas dapibus augue ut urna malesuada, non tempor nibh mollis. Donec sed sem sollicitudin, convallis velit aliquam, tincidunt diam. In eu venenatis lorem. Aliquam non augue porttitor tellus faucibus porta et nec ante. Proin sodales, libero vitae commodo sodales, dolor nisi cursus magna, non tincidunt ipsum nibh eget purus. Nam rutrum tincidunt arcu, tincidunt vulputate mi sagittis id. Proin et nisi nec orci tincidunt auctor et porta elit. Praesent eu dolor ac magna cursus euismod. Integer non dictum nunc.

¹My footnote goes blah blah blah! ...

Subplots

I can cite Wall-E (see Fig. 3.1b) and Minions in despicable me (Fig. 3.1c) or I can cite the whole figure as Fig. 3.1

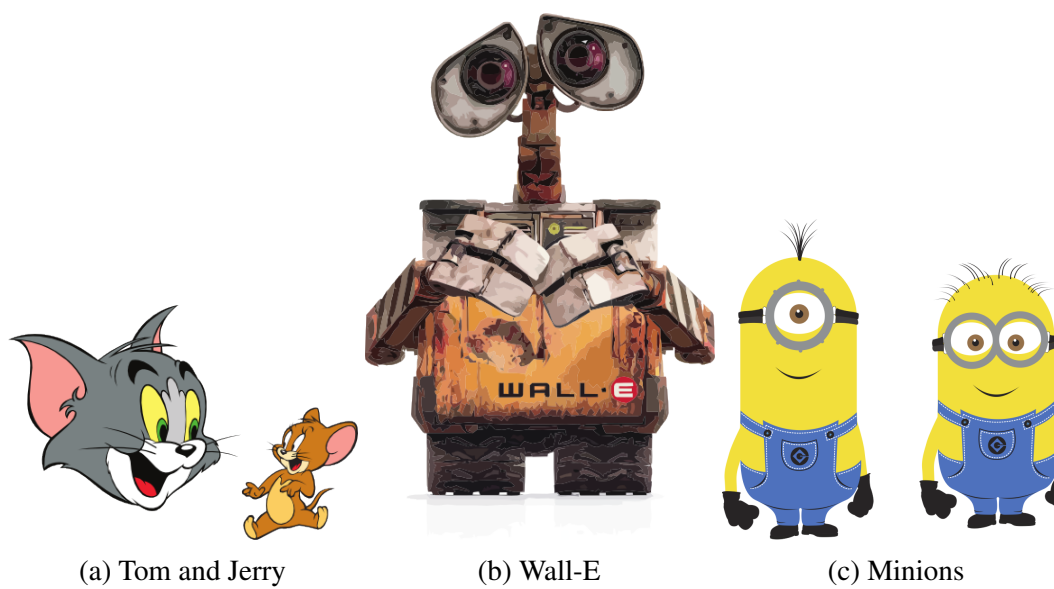


Fig. 2.1 Best Animations

Chapter 3

Inhomogeneous Electroluminescence in InGaN QW LEDs

3.1 Background

$\text{In}_x\text{Ga}_{1-x}\text{N}/\text{GaN}$ quantum well (QW) structures are key structures in present day light emitting diodes in the visible wavelengths. Despite the growth of III-nitride LEDs into a gigantic market with a projected overall worth of 64 billion EUR by 2020, III-nitride alloys suffer from a plethora of material issues arising from heteroepitaxial growth on foreign substrates with large lattice mismatches [3]. A notorious issue in III-nitride growth is the high density of threading dislocations which are the source of highly undesirable effects in diode structures such as non-radiative recombination [9] and leakage current [3].

Threading dislocations have been shown to result in inverted pyramidal defects at the surface of nitride epilayers, known as 'V defects'. The effect of these defects on LED performance is hotly debated in literature as they are expected by many to hinder LED performance due to their association with TDs. However, it has been shown that narrower QWs along the sidewalls of V-defects serve to screen carriers from the non-radiative centres at TDs

Enumeration

1. The first topic is dull
2. The second topic is duller
 - (a) The first subtopic is silly
 - (b) The second subtopic is stupid

3. The third topic is the dullest

itemize

- The first topic is dull
- The second topic is duller
 - The first subtopic is silly
 - The second subtopic is stupid
- The third topic is the dullest

description

The first topic is dull

The second topic is duller

The first subtopic is silly

The second subtopic is stupid

The third topic is the dullest

3.2 Hidden section

Lorem ipsum dolor sit amet, consectetur adipiscing elit. In magna nisi, aliquam id blandit id, congue ac est. Fusce porta consequat leo. Proin feugiat at felis vel consectetur. Ut tempus ipsum sit amet congue posuere. Nulla varius rutrum quam. Donec sed purus luctus, faucibus velit id, ultrices sapien. Cras diam purus, tincidunt eget tristique ut, egestas quis nulla. Curabitur vel iaculis lectus. Nunc nulla urna, ultrices et eleifend in, accumsan ut erat. In ut ante leo. Aenean a lacinia nisl, sit amet ullamcorper dolor. Maecenas blandit, tortor ut scelerisque congue, velit diam volutpat metus, sed vestibulum eros justo ut nulla. Etiam nec ipsum non enim luctus porta in in massa. Cras arcu urna, malesuada ut tellus ut, pellentesque mollis risus. Morbi vel tortor imperdiet arcu auctor mattis sit amet eu nisi. Nulla gravida urna vel nisl egestas varius. Aliquam posuere ante quis malesuada dignissim. Mauris ultrices tristique eros, a dignissim nisl iaculis nec. Praesent dapibus tincidunt mauris nec tempor. Curabitur et consequat nisi. Quisque viverra egestas risus, ut sodales enim blandit at. Mauris quis odio nulla. Cras euismod turpis magna, in facilisis diam congue non. Mauris faucibus nisl a orci dictum, et tempus mi cursus.

Etiam elementum tristique lacus, sit amet eleifend nibh eleifend sed ¹. Maecenas dapibus augue ut urna malesuada, non tempor nibh mollis. Donec sed sem sollicitudin, convallis velit aliquam, tincidunt diam. In eu venenatis lorem. Aliquam non augue porttitor tellus faucibus porta et nec ante. Proin sodales, libero vitae commodo sodales, dolor nisi cursus magna, non tincidunt ipsum nibh eget purus. Nam rutrum tincidunt arcu, tincidunt vulputate mi sagittis id. Proin et nisi nec orci tincidunt auctor et porta elit. Praesent eu dolor ac magna cursus euismod. Integer non dictum nunc.

¹My footnote goes blah blah blah! ...

Subplots

I can cite Wall-E (see Fig. 3.1b) and Minions in despicable me (Fig. 3.1c) or I can cite the whole figure as Fig. 3.1

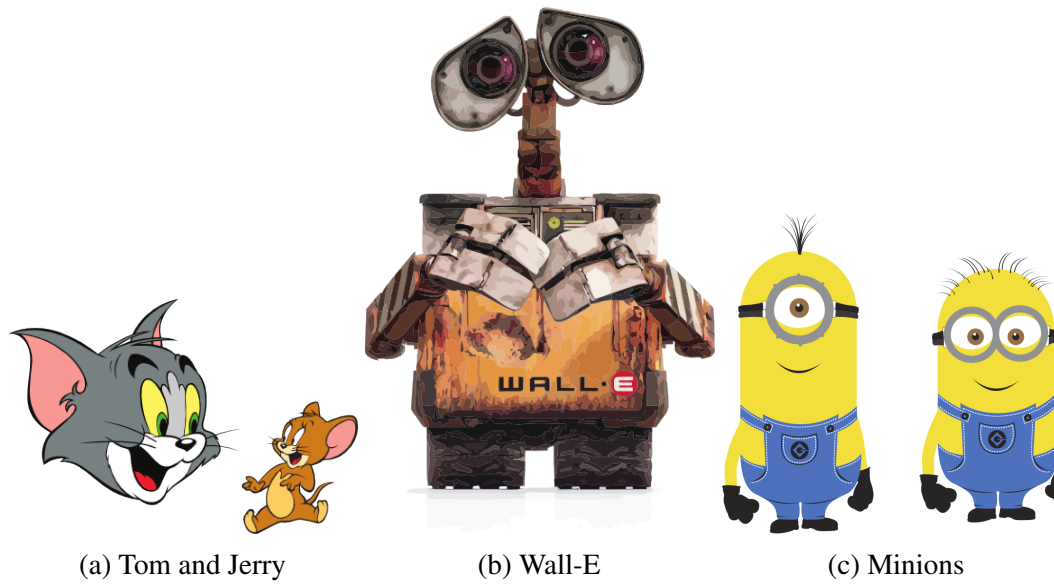


Fig. 3.1 Best Animations

References

- [1] C. J. Humphreys, “USE Solid-State Lighting,” vol. 33, no. April, pp. 459–471, 2008.
- [2] S. Nakamura, T. Mukai, and M. Senoh, “High-Power GaN P-N Junction Blue-Light-Emitting Diodes,” *Japanese Journal of Applied Physics*, vol. 30, no. 12A, pp. 1998–2001, 1991.
- [3] S. E. Bennett, “Dislocations and their reduction in GaN,” *Materials Science and Technology*, vol. 26, no. 9, pp. 1017–1028, 2010.
- [4] I. Vurgaftman and J. R. Meyer, “Band parameters for nitrogen-containing semiconductors,” *Journal of Applied Physics*, vol. 94, no. 6, pp. 3675–3696, 2003.
- [5] M. E. Vickers, M. J. Kappers, T. M. Smeeton, E. J. Thrush, J. S. Barnard, and C. J. Humphreys, “Determination of the indium content and layer thicknesses in InGaN/GaN quantum wells by x-ray scattering,” *Journal of Applied Physics*, vol. 94, no. 3, pp. 1565–1574, 2003.
- [6] O. Ambacher and J. Majewski, “Pyroelectric properties of Al (In) GaN/GaN hetero- and quantum well structures,” *Journal of physics: ...*, vol. 3399, 2002.
- [7] C. X. Ren, “Polarisation fields in III-nitrides: effects and control,” *Materials Science and Technology*, vol. 00, no. 0, p. 1743284715Y.000, 2015.
- [8] M. Sumiya and S. Fuke, “Review of polarity determination and control of GaN,” *MRS Internet Journal of Nitride Semiconductor Research*, vol. 9, no. 1, pp. 1–32, 2004.
- [9] M. Albrecht, J. L. Weyher, B. Lucznik, I. Grzegory, and S. Porowski, “Nonradiative recombination at threading dislocations in n-type GaN: Studied by cathodoluminescence and defect selective etching,” *Applied Physics Letters*, vol. 92, no. 23, pp. 0–3, 2008.

Appendix A

How to install L^AT_EX

Windows OS

TeXLive package - full version

1. Download the TeXLive ISO (2.2GB) from
<https://www.tug.org/texlive/>
2. Download WinCDEmu (if you don't have a virtual drive) from
<http://wincdemu.sysprogs.org/download/>
3. To install Windows CD Emulator follow the instructions at
<http://wincdemu.sysprogs.org/tutorials/install/>
4. Right click the iso and mount it using the WinCDEmu as shown in
<http://wincdemu.sysprogs.org/tutorials/mount/>
5. Open your virtual drive and run setup.pl

or

Basic MikTeX - T_EX distribution

1. Download Basic-MiK_TE_X(32bit or 64bit) from
<http://miktex.org/download>
2. Run the installer
3. To add a new package go to Start » All Programs » MikTeX » Maintenance (Admin)
and choose Package Manager

4. Select or search for packages to install

TexStudio - T_EX editor

1. Download TexStudio from
<http://texstudio.sourceforge.net/#downloads>
2. Run the installer

Mac OS X

MacTeX - T_EX distribution

1. Download the file from
<https://www.tug.org/mactex/>
2. Extract and double click to run the installer. It does the entire configuration, sit back and relax.

TexStudio - T_EX editor

1. Download TexStudio from
<http://texstudio.sourceforge.net/#downloads>
2. Extract and Start

Unix/Linux

TeXLive - T_EX distribution

Getting the distribution:

1. TeXLive can be downloaded from
<http://www.tug.org/texlive/acquire-netinstall.html>.
2. TeXLive is provided by most operating system you can use (rpm,apt-get or yum) to get TeXLive distributions

Installation

1. Mount the ISO file in the mnt directory

```
mount -t iso9660 -o ro,loop,noauto /your/texlive####.iso /mnt
```

2. Install wget on your OS (use rpm, apt-get or yum install)
3. Run the installer script install-tl.

```
cd /your/download/directory
./install-tl
```

4. Enter command 'i' for installation
5. Post-Installation configuration:
<http://www.tug.org/texlive/doc/texlive-en/texlive-en.html#x1-320003.4.1>
6. Set the path for the directory of TexLive binaries in your .bashrc file

For 32bit OS

For Bourne-compatible shells such as bash, and using Intel x86 GNU/Linux and a default directory setup as an example, the file to edit might be

```
edit ~/.bashrc file and add following lines
PATH=/usr/local/texlive/2011/bin/i386-linux:$PATH;
export PATH
MANPATH=/usr/local/texlive/2011/texmf/doc/man:$MANPATH;
export MANPATH
INFOPATH=/usr/local/texlive/2011/texmf/doc/info:$INFOPATH;
export INFOPATH
```

For 64bit OS

```
edit ~/.bashrc file and add following lines
PATH=/usr/local/texlive/2011/bin/x86_64-linux:$PATH;
export PATH
MANPATH=/usr/local/texlive/2011/texmf/doc/man:$MANPATH;
export MANPATH
```

```
INFOPATH=/usr/local/texlive/2011/texmf/doc/info:$INFOPATH;  
export INFOPATH
```

Fedora/RedHat/CentOS:

```
sudo yum install texlive  
sudo yum install psutils
```

SUSE:

```
sudo zypper install texlive
```

Debian/Ubuntu:

```
sudo apt-get install texlive texlive-latex-extra  
sudo apt-get install psutils
```

Appendix B

Installing the CUED class file

\LaTeX .cls files can be accessed system-wide when they are placed in the $\langle\text{texmf}\rangle/\text{tex}/\text{latex}$ directory, where $\langle\text{texmf}\rangle$ is the root directory of the user's \TeX installation. On systems that have a local texmf tree ($\langle\text{texmflocal}\rangle$), which may be named “ texmf-local ” or “ localtexmf ”, it may be advisable to install packages in $\langle\text{texmflocal}\rangle$, rather than $\langle\text{texmf}\rangle$ as the contents of the former, unlike that of the latter, are preserved after the \LaTeX system is reinstalled and/or upgraded.

It is recommended that the user create a subdirectory $\langle\text{texmf}\rangle/\text{tex}/\text{latex}/\text{CUED}$ for all CUED related \LaTeX class and package files. On some \LaTeX systems, the directory look-up tables will need to be refreshed after making additions or deletions to the system files. For \TeX Live systems this is accomplished via executing “ texhash ” as root. MikTeX users can run “ initexmf -u ” to accomplish the same thing.

Users not willing or able to install the files system-wide can install them in their personal directories, but will then have to provide the path (full or relative) in addition to the filename when referring to them in \LaTeX .

